MD.103.	
Title	Technology to prepare the single-crystals layers for thermoelectric applications (microcoolers).
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Patent no.	MD 1366 Z 2020.03.31 Procedeu de obținere a peliculelor monocristaline subțiri
Description	
	INTERNATIONAL EXHIBITS

## **EUROINVENT 2021**

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The primary purpose of the given presentation was to develop new reliable and reproducible engineering techniques to prepare low-dimensional structures (single-crystals layers) of bismuth telluride and semiconductor bismuth—antimony topological insulator (TI) *n*-and *p*-type for thermoelectric applications (microcoolers).

Single crystals of Bi<sub>2</sub>Te<sub>3</sub> layers (1–20 µm) were prepared using the mechanical exfoliation method by cleaving a thin layer from bulk crystalline Bi<sub>2</sub>Te<sub>3</sub> and Bi<sub>1-x</sub>Sb<sub>x</sub> samples. Using a mechanical cleavage process, thin layers were separated from the crystalline bulk. The process was repeated several times to obtain layers with different thickness. To peel Bi<sub>1-x</sub>Sb<sub>x</sub> layers off using an adhesive tape, the bulk sample was cooled to 70 K to increase the interatomic distance and thereby to provide a decrease in the interaction (Van der Waals) forces  $P = m/d^2$  (patent). Using p- and n-type layers as n- and p-legs of a thermoelement,  $\Delta T = 4$ °C was obtained at 300 K on a cross section of  $1 \times 10^{-4}$  cm<sup>2</sup>. The use of a segmentation method (increasing the cross section as high as to a value of  $5 \times 10^{-4}$  cm<sup>2</sup>) made it possible to obtain  $\Delta T = 8$ °C.

It is known that an increase in the temperature of the micro- sensor by 10°C leads to a twofold decrease the sensor durability.

Our experimental samples the thermoelectric microcoolers with efficient cooling capacity, small areas, short response time and with reproducible engineering techniques are in high demand on the telecommunication markets of the future.

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